Etch-pit formation-a convective diffusion process

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Etch-pit formation is one of the numerous physical phenomena which can be understood as convective diffusion processes. The general theory of such processes is given by Levich (Levich 1962; see also Daccord 1987). Preliminary investigations in this direction were carried out by the present authors a few years ago.

We begin by writing down the differential equations for convective-diffusion processes (v is the fluid velocity, c the concentration of the etchant, other symbols are standard):

$$\frac{\partial \mathbf{v}}{\partial t} + (\mathbf{v}.\mathbf{p})\mathbf{v} = -\frac{\mathbf{p}\mathbf{p}}{\mathbf{p}_{sol.}} + \mathbf{v}\mathbf{p}^{\mathbf{s}}\mathbf{v} \qquad \text{(Navier-Stokes eqn.)} \tag{1}$$

$$\frac{\partial c}{\partial t} + (\mathbf{v}.\mathbf{p})\mathbf{c} = \mathbf{D}\mathbf{p}^{\mathbf{s}}\mathbf{c} \qquad \text{(eqn. for convective diffusion)} \tag{2}$$

We choose a coordinate system with origin at the vertex of the pit in the SSNTD. The track will be assumed to be perpendicular to the flat surface of the detector, and the (+) ve direction of the Z-axis oriented back along the track. We can now specify the boundary conditions :

(i) $c \xrightarrow{} c_{0}$ (ii) $D\left(\frac{\partial c}{\partial n}\right) = Kc$, on the reaction front (walls of the pit),

where

$$K = K_0[1 + \alpha l],$$

I = I(r, t) = ionization density in the detector, and K_o , κ are two constants.

An approximate solution of this convective-diffusion problem can be worked out in the quasi-stationary limit :

$$\frac{\partial \mathbf{v}}{\partial t} \simeq 0, \ \frac{\partial c}{\partial t} \simeq 0.$$
 (3)

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Actually, inside the pit, $\nu \simeq 0$, since the track etch rate $V_t \sim \text{few } \mu \text{m/hr}$.

Thus we are essentially left to solve the differential eqn. $p^{2}c=0$, i.e.,

$$\frac{\partial^2 c}{\partial \rho^2} + \frac{1}{\rho} \frac{\partial c}{\partial \rho} + \frac{\partial^2 c}{\partial z^2} = 0$$
(4)

in the cylindrical polar coordinates.

Now, on general physical grounds, we expect a narrow pit, conical in shape in a first approximation. Since a cone is characterized by a constant value of the ratio (ρ/z) , the following appears to be a plausible solution of the problem :

Eqn. (4) remains unchanged when the variables are transformed as follows ;

$$\rho \to \lambda \rho', \ z \to \lambda z'$$
 (5)

In view of this, a solution of eqn. (4) may be sought such that a combination of variables ρ and z remains unchanged by transformations (5); such a combination is

$$\eta = \frac{\rho}{z}$$

Setting $c = c(\eta)$. we can write eqn. (4) in the form

$$(1+\eta^2)\frac{d^2c}{d\eta^2} + \left(2\eta + \frac{1}{\eta}\right)\frac{dc}{d\eta} = 0$$

This equation can be solved easily (for $\eta > 0$). We have

$$\frac{dc}{d\eta} = \frac{A}{\eta(1+\eta^2)^{1/2}} = \frac{Az^2}{\rho(\rho^2+z^2)^{1/2}}$$

where $A(\langle 0)$ is to be fixed from the boundary condition (ii).

Finally, for fixed z,

$$c(\rho, z) = c(\eta) = \int_{\eta_0}^{\eta} \left(\frac{dc}{d\eta}\right) d\eta + c(\eta_0) \left[\rho_0 \ge 0.1 \ \mu\text{m}\right]$$

Now the rate (dR/dt) at which the radius (R) of the pit, for a given h (depth, referred to the point of entry of the particle into the SSNTD), changes with time, is proportional to the diffusional flux rate (j_{diff}) of the etchant on to the surface of the pit. Again

$$J_{arr}(R, z) = D \frac{\partial c}{\partial n}\Big|_{R,z} = -\frac{DA}{R}$$

and

$$\frac{dR}{dt} \propto \sqrt{1 + \frac{R^2}{z^2}} \cdot \frac{D \mid A \mid}{R}$$
(6)

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Since, on physical grounds, $z = \int V_t dt - h$ (where V_t is the track etch rate) is much larger than R, eqn. (6) reduces to

$$\frac{dR}{dt} \sim \frac{1}{R}$$

Thus

 $R \sim t^{1/2}$ (for fixed h)

Actually, this solution does not correspond exactly to a conical etch pit; but we should remember that a cone is an approximation for the shape of the pit.

If $\frac{\partial^3 c}{\partial z^3}$ be negligible, then the eqn. for convective-diffusion, near the walls of the pit, can be written as

$$V_t \frac{\partial c}{\partial z} = D \left(\frac{\partial^3 c}{\partial \rho^2} + \frac{1}{\rho} \frac{\partial c}{\partial \rho} \right)$$
(7)

Scaling arguments show that we may express $c(\rho, z)$ as a function of $\zeta = \frac{\rho}{z^{1/2}}$. This time the differential eqn. (7) reduces to

$$\frac{d^2c}{d\zeta^2} + \left(k\zeta + \frac{1}{\zeta}\right)\frac{dc}{d\zeta} = 0$$

where

 $k = \frac{V_t}{2D} \ll 1.$

Thus

$$\frac{dc}{d\zeta} = \frac{Ae^{-\frac{H}{2}\zeta^2}}{\zeta}$$

Finally,

$$\frac{dR}{dt} \propto \frac{1}{z^{1/2}} \left(1 + \frac{R^2}{4z^2} \right) \frac{dc}{d\zeta} \bigg|_{R,s} \xrightarrow[(s>>R)]{} \frac{dR}{dt} \sim \frac{1}{\bar{R}}$$

Consequently we again get

$$R \sim t^{1/2}$$
 (at fixed h).

Since $z \sim t$ (for fixed h), therefore $R \sim z^{1/3}$. If the initial boundary condition is something like $c \simeq 0$ on $\zeta = \zeta_0$, i.e. $c(\zeta_0) \simeq 0$, then, because $R \sim z^{1/3}$, $c(\zeta_0) \simeq 0$ at all later times. Thus $R^3 \simeq \zeta_0^3 z$ represents the etch pit for large times.

We, therefore, conclude that in either case the etch pit should look somewhat like a paraboloid rather than a cone.

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References

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